

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

IN RE APPLICATION OF:

Adolf KUEHNLE, et al.

GROUP: 2812

SERIAL NO: 10/563,450

FILED: April 14, 2006

EXAMINER: PATEL, REEMA

FOR: PROCESS FOR PRODUCING LOW-K DIELECTRIC FILMS

**SUBMISSION OF SUPPLEMENTAL APPLICATION DATA SHEET**

Office of Initial Patent Examination  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

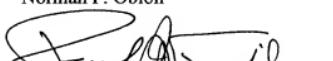
**COPY**

Sir:

Applicant(s) submit herewith a Supplemental Application Data Sheet for the above-identified application for the purpose of correcting the 2<sup>nd</sup> inventor's city of residence, his mailing address and the Foreign Priority information.

Respectfully Submitted,

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